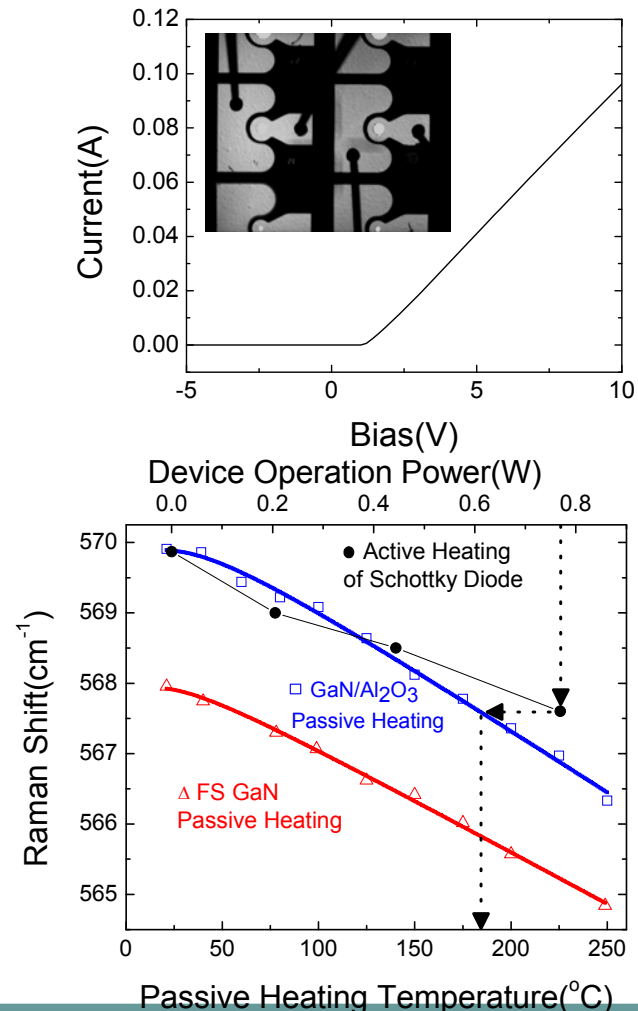
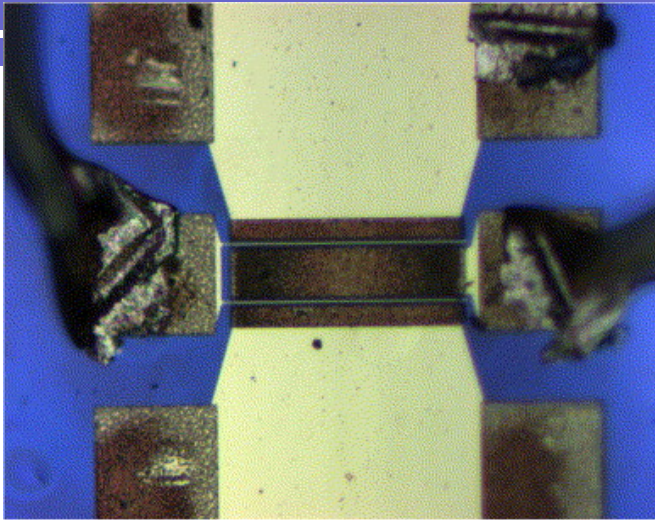


μ -Raman(collaboration with Jaime Freitas and Jihyun Kim)

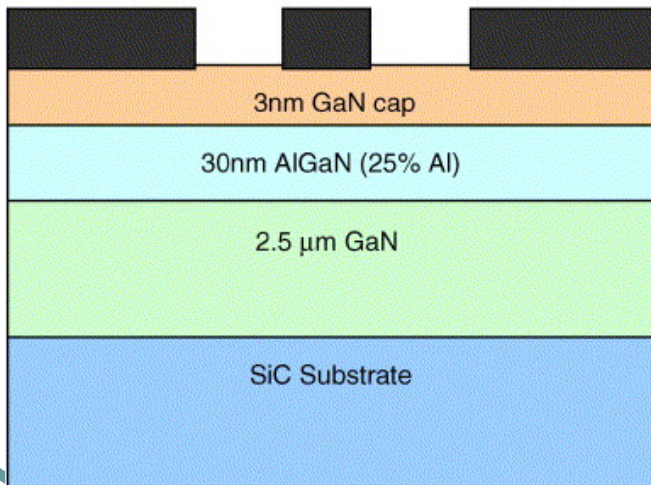
- Contact-free and non-destructive.
- Spatial resolution typically $\leq 1\text{ }\mu\text{m}$, compared with conventional infrared technique (IR) with $15\text{ }\mu\text{m}$ spatial resolution. IR is not suitable for current advanced device designs because the channel spacing is normally less than $5\text{ }\mu\text{m}$.
- First order Raman Scattering spectroscopy can be directly measure device temperature with high spatial resolution and has been previously used to access device temperatures by monitoring phonon frequency shift with temperature.
- “Effective temperature measurements of AlGaN/GaN-based HEMT under various load lines using micro-Raman technique”, Solid-State Electron., 50, 408(2006), Jihyun Kim, Jr., J.A. Freitas, J. Mittereder, R. Fitch, B.S. Kang, S.J. Pearton and F. Ren.



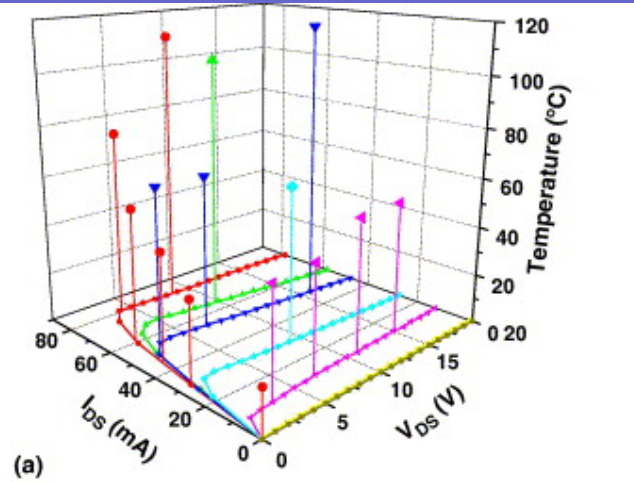
Raman scattering of GaN HEMTs



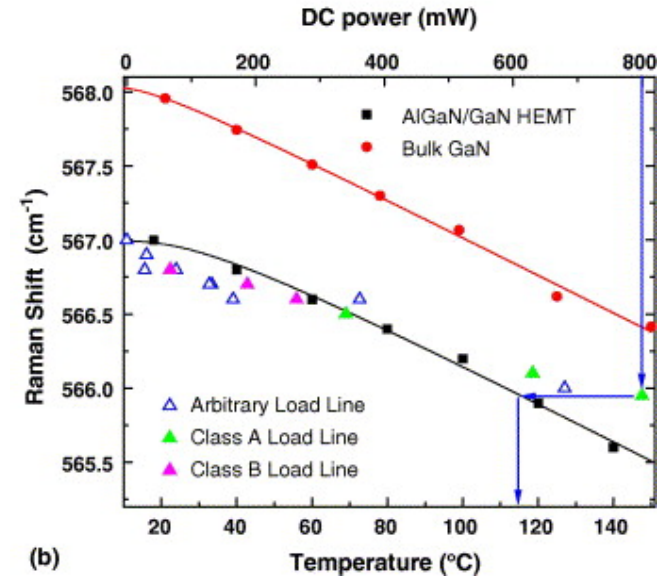
(a)



(b)



(a)

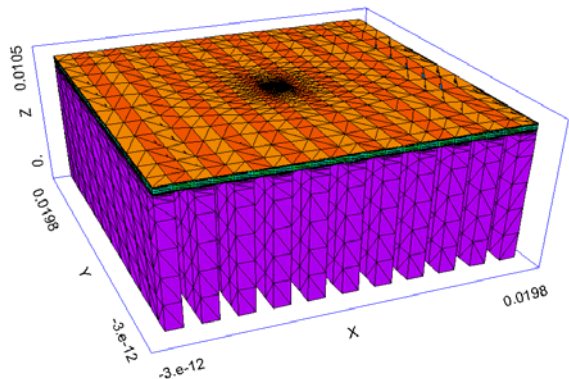


(b)

Thermal Simulations

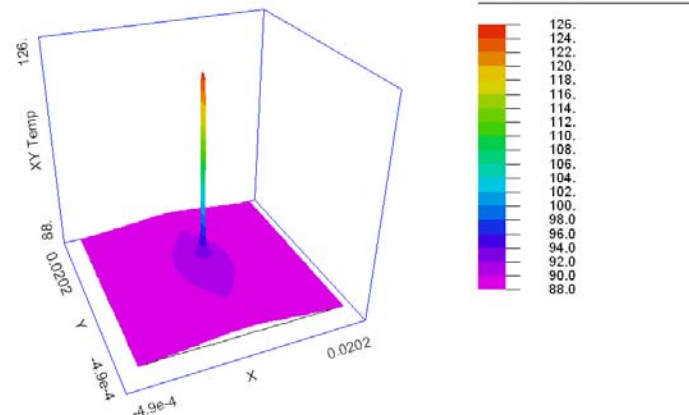
- Use finite element modeling to optimize package design
- Most important factors in thermal management: heat transfer at the system boundaries and substrate thickness

3D Domain



Integrated Heat Sink Antenna (3-D)

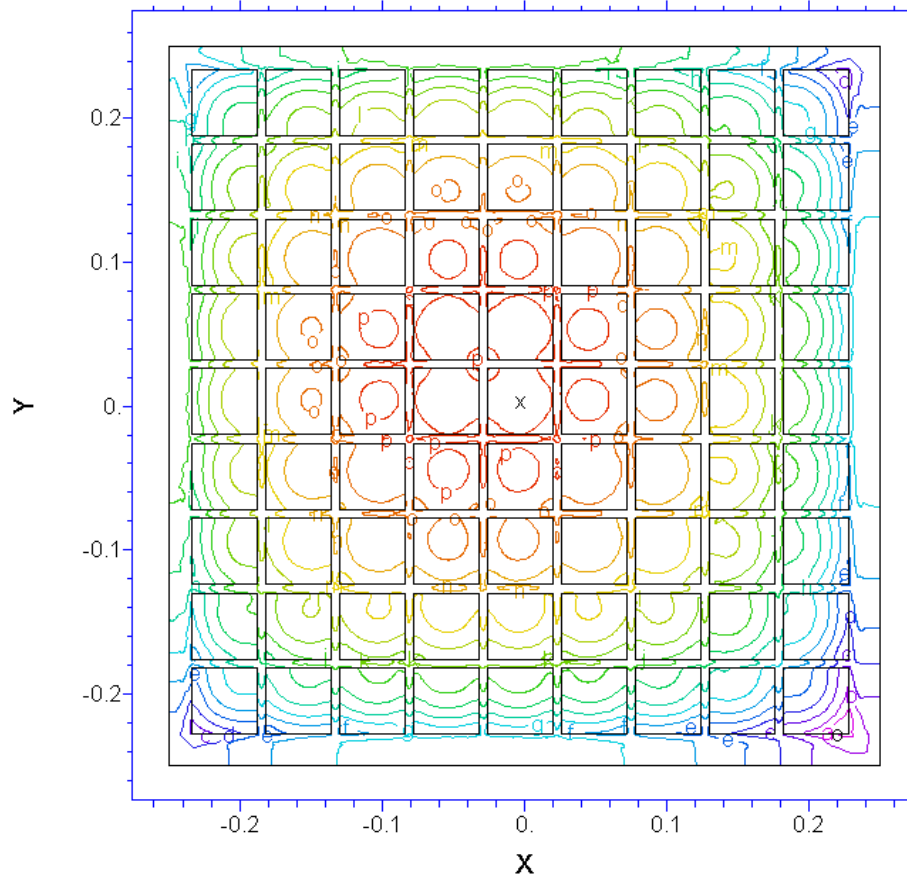
14:11:19 5/26/05
FlexPDE 3.11



inv_ant_ss_3d: Grid#1 p2 Nodes=606535 Cells=437742 RMS Err= 2.e-7
Integral= 0.034810

Top of the chip

3D-conduction in GaN bulk diodes with flip chip bonding

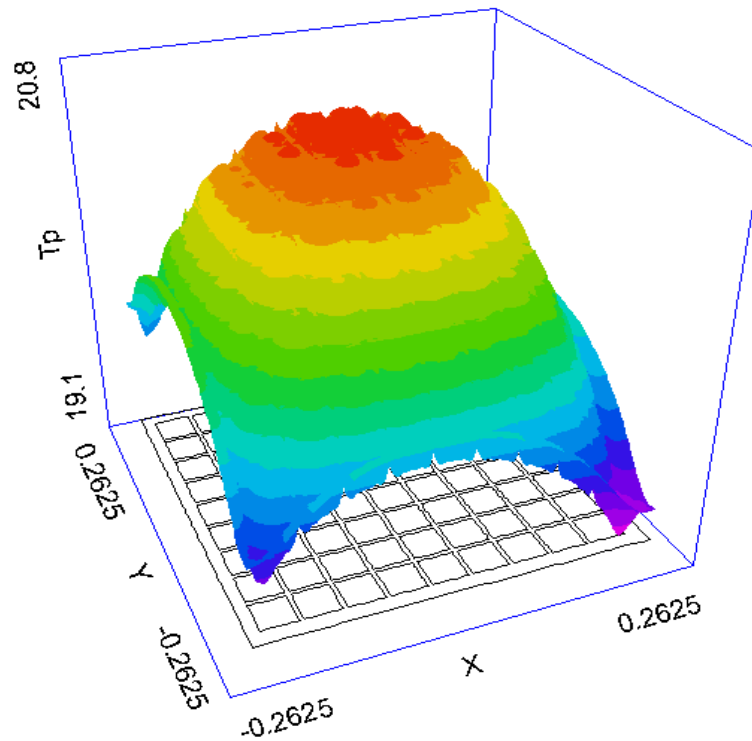


**Temperature rise from
room temperature (°C)**

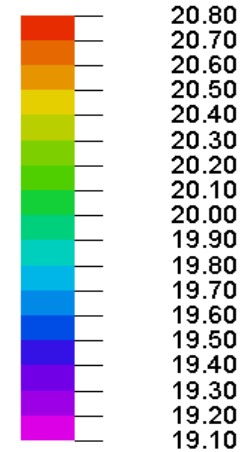
| | |
|-----|-------|
| max | 20.78 |
| p : | 20.70 |
| o : | 20.60 |
| n : | 20.50 |
| m : | 20.40 |
| l : | 20.30 |
| k : | 20.20 |
| j : | 20.10 |
| i : | 20.00 |
| h : | 19.90 |
| g : | 19.80 |
| f : | 19.70 |
| e : | 19.60 |
| d : | 19.50 |
| c : | 19.40 |
| b : | 19.30 |
| a : | 19.20 |
| min | 19.15 |

Top of the chip

3D-conduction in GaN bulk diodes with flip chip bonding

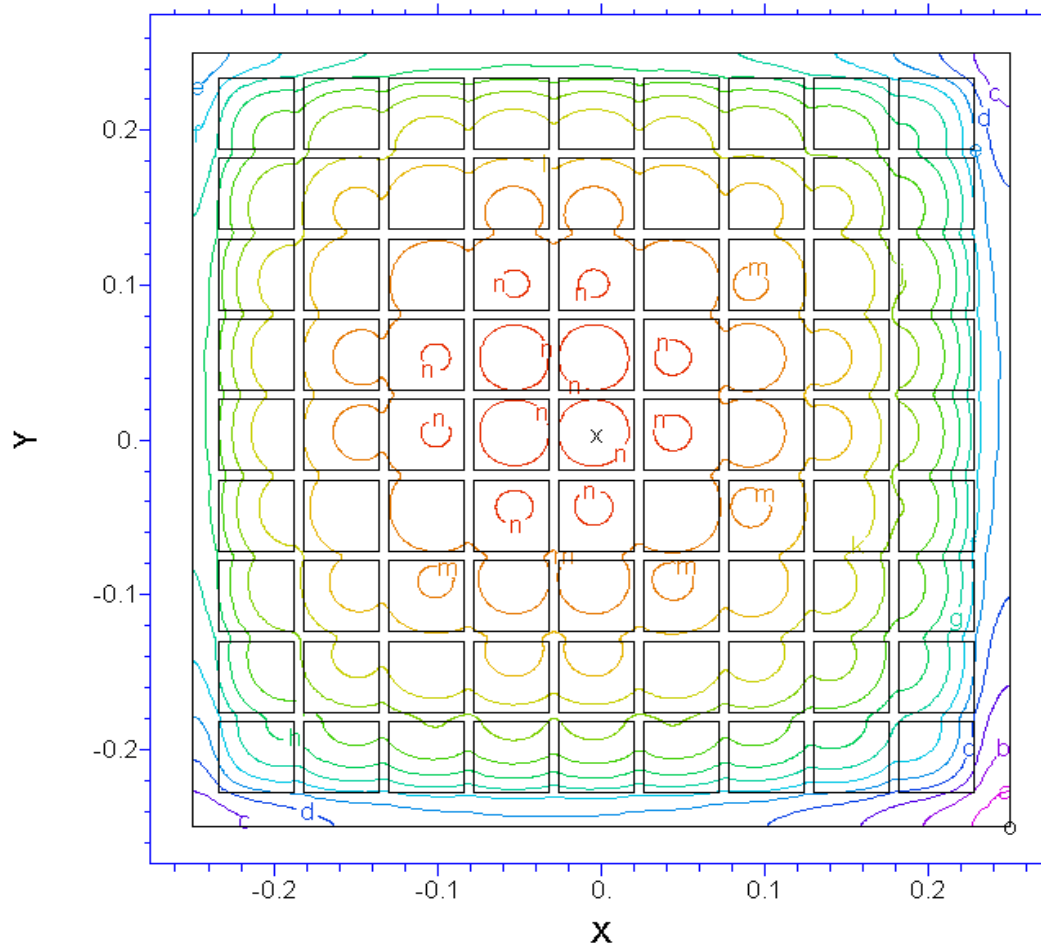


**Temperature rise from
room temperature (°C)**



Top of the chip

3D-conduction in GaN bulk diodes without flip chip bonding

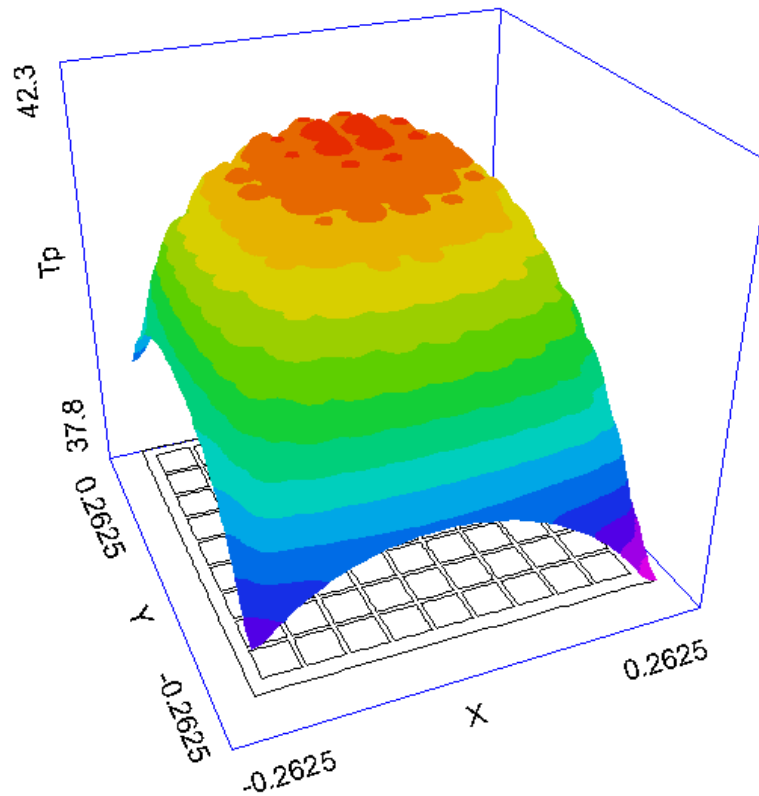


Temperature rise from
room temperature (°C)

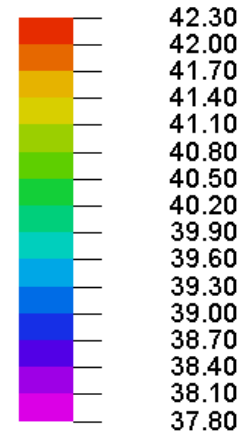
| | |
|-----|-------|
| max | 42.13 |
| n : | 42.00 |
| m : | 41.70 |
| l : | 41.40 |
| k : | 41.10 |
| j : | 40.80 |
| i : | 40.50 |
| h : | 40.20 |
| g : | 39.90 |
| f : | 39.60 |
| e : | 39.30 |
| d : | 39.00 |
| c : | 38.70 |
| b : | 38.40 |
| a : | 38.10 |
| min | 37.96 |

Top of the chip

3D-conduction in GaN bulk diodes without flip chip bonding

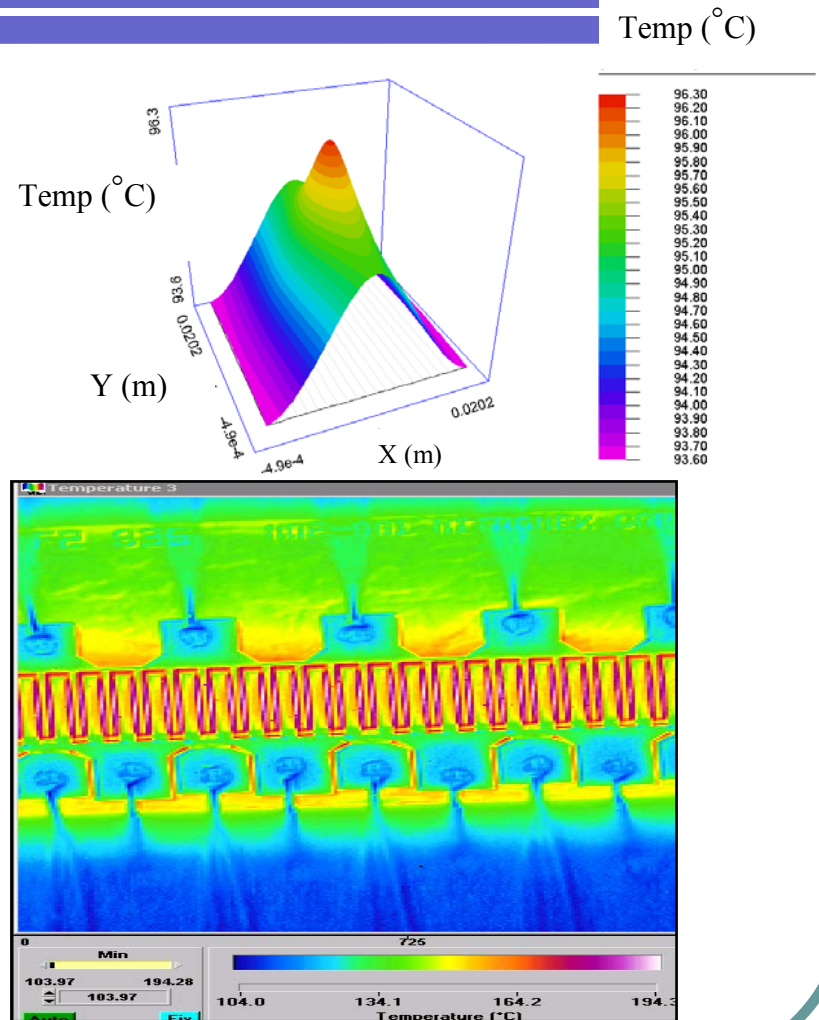


**Temperature rise from
room temperature (°C)**



Thermal Simulations and IR Imaging

- T(Junc) of power devices is often significantly hotter than T(stage)
- Accurate extraction of activation energy requires knowledge of the true channel temperature.
- We have extensive experience in estimating heat transfer even in complex structures
- Purchasing a high-resolution IR camera for direct imaging of the device operating temperature. We have collaborated with Nitronex on thermal imaging-a typical example is shown at right for a multi-finger power HEMT.

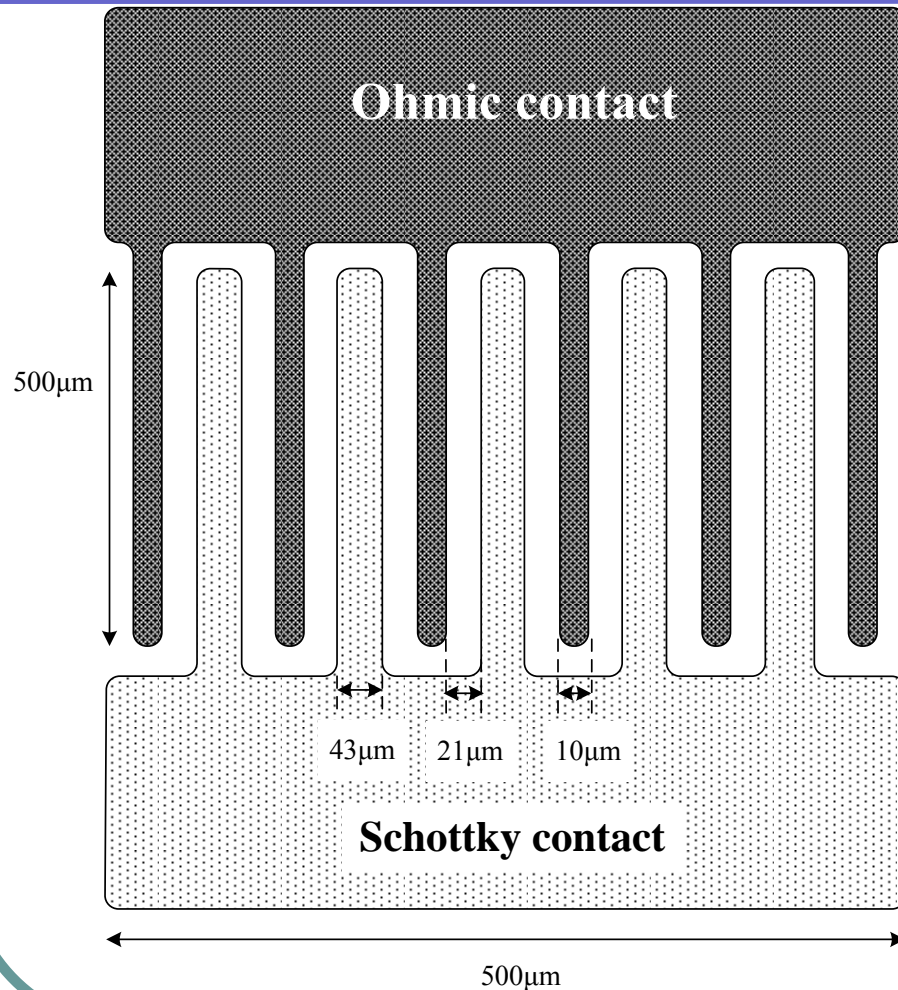


Epilayer Structures of HEMT-collaboration with NCU in Taiwan

| |
|-------------------------------------|
| Al_{0.22}GaN (12 nm) |
| AlN (0.5nm) |
| GaN (2μm) |
| Si |

| | |
|--|--------------------------|
| Sheet carrier concentration (1/cm ²) | -1.12 X 10 ¹³ |
| Mobility (cm ² /Vs) | 1120 |
| Sheet resistance (ohm/sq) | 471.3 |

Layout of 5-fingers SBD



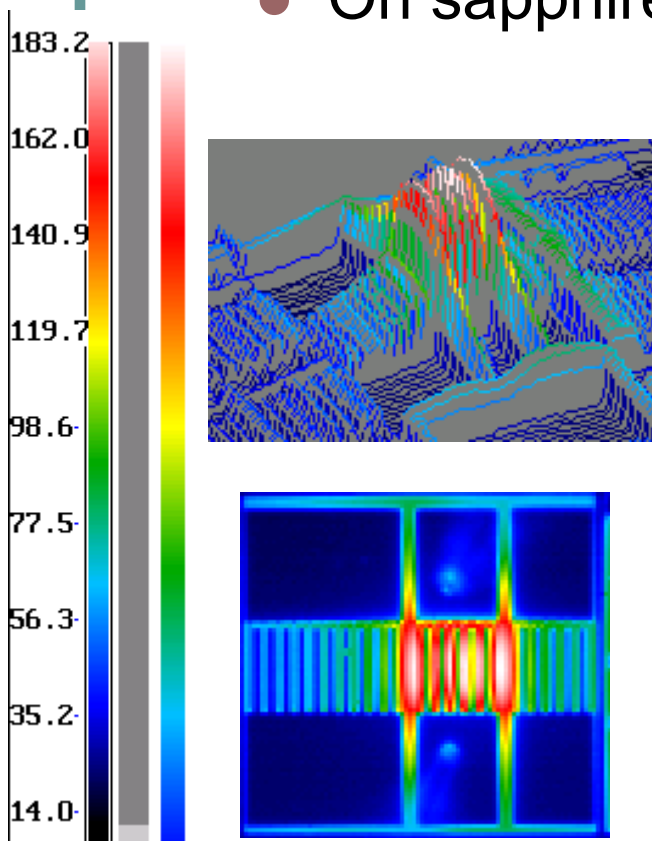
Process Flow:

1. Etch mesa (300nm depth)
2. Ohmic contact (2500nm thickness)
3. Schottky contact & pad ($1.5\mu\text{m}$ thickness)

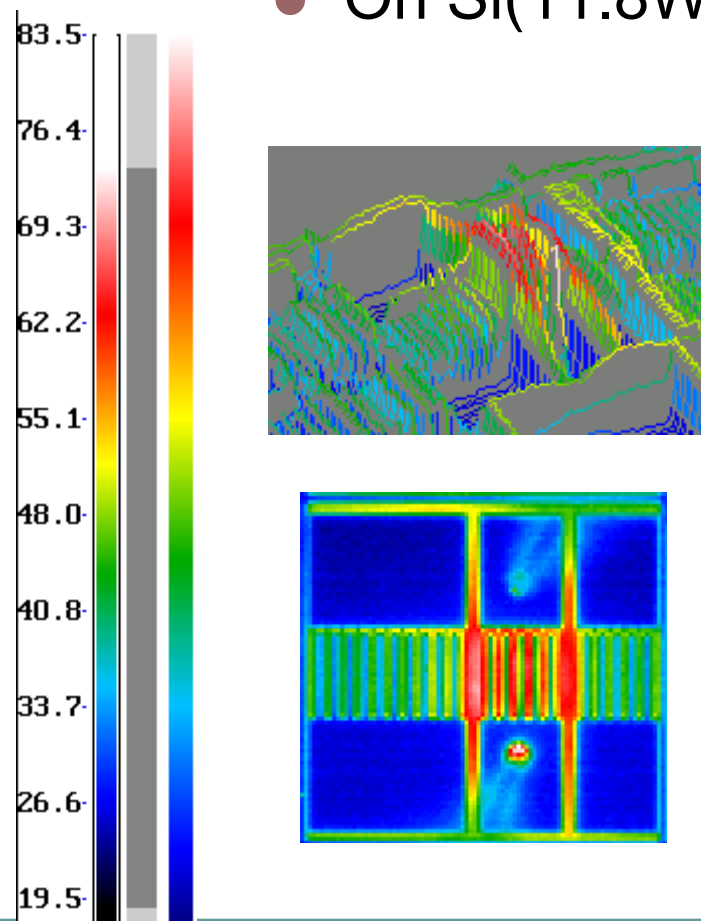
$V_{\text{RB}} \sim 200\text{ V}$

3D Thermal Images

- On sapphire (4.2 W)

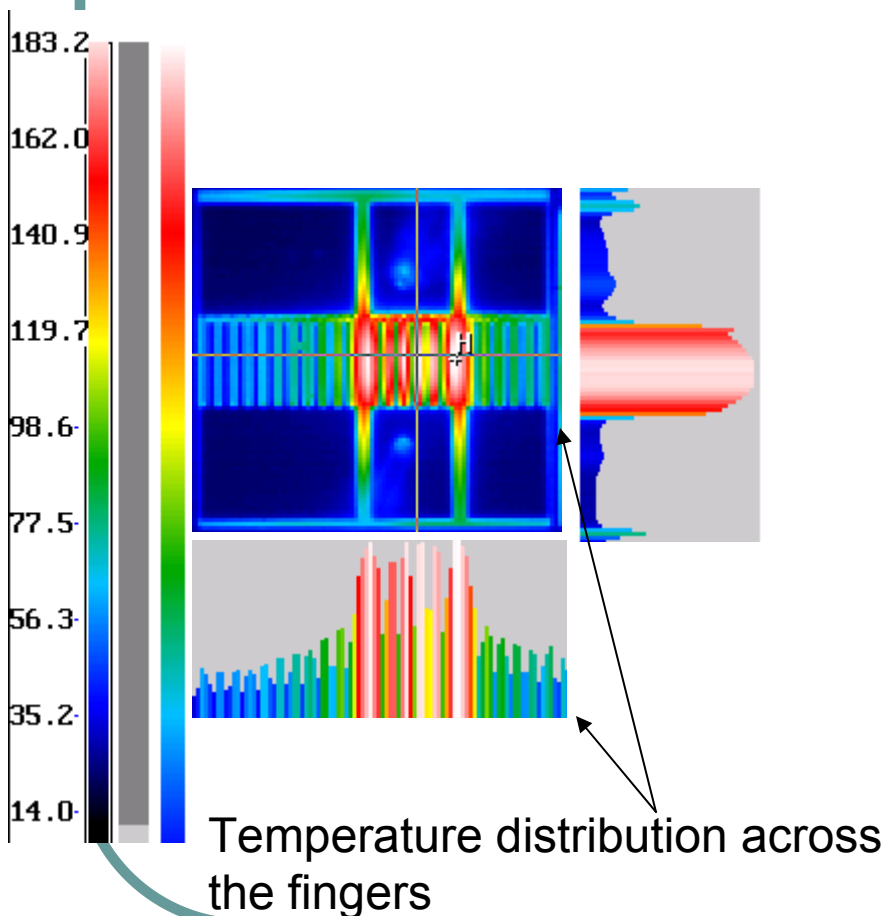


- On Si(11.8W)

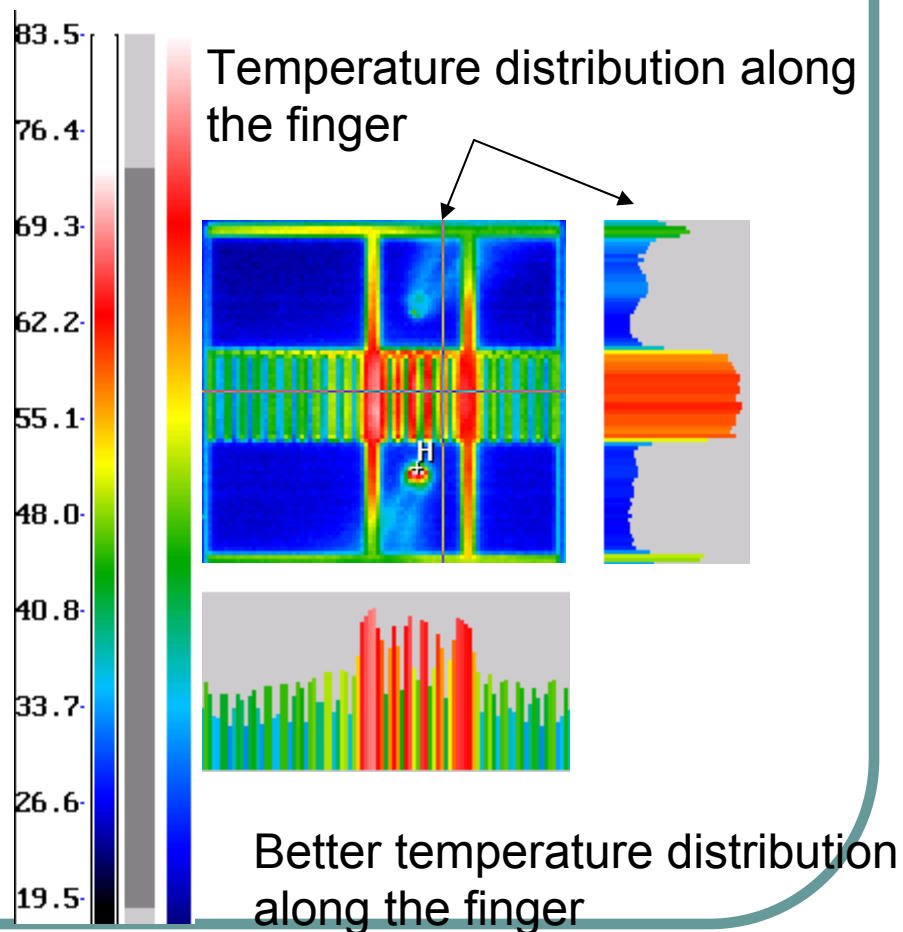


Cross Sectional Thermal Images

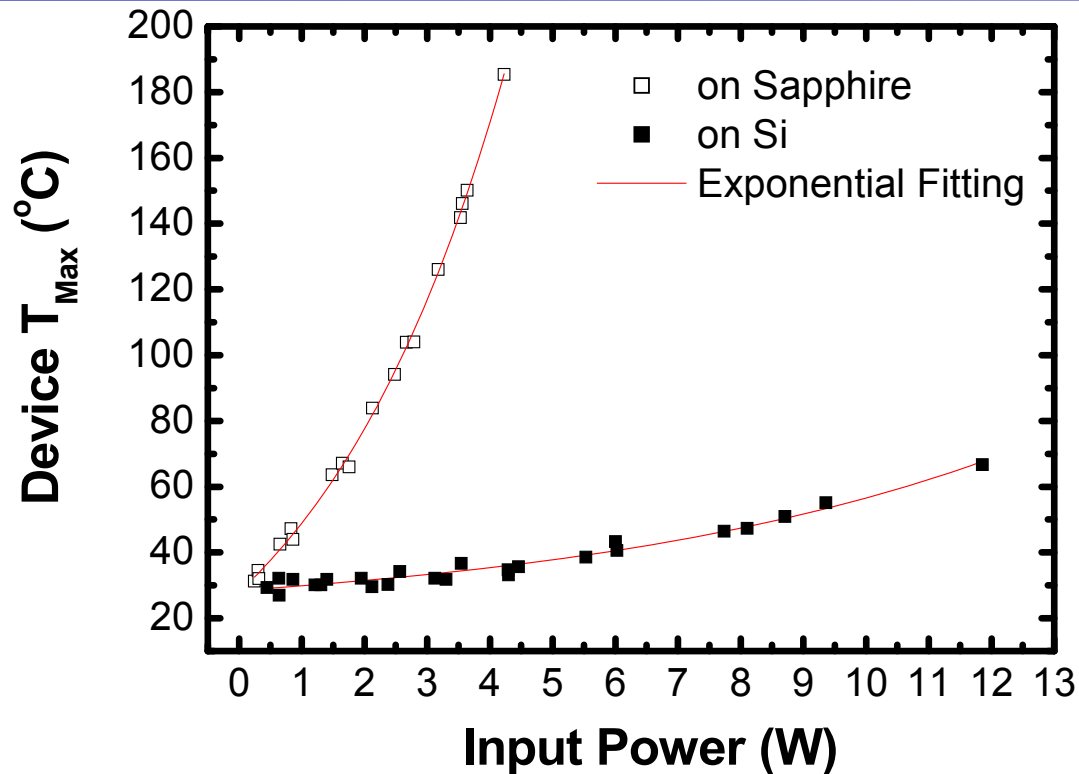
- On sapphire (4.2 W)



- On Si(11.8W)



Temperature vs. input power



- 5 Fingers SBD ($500 \times 500 \mu\text{m}^2$)
 $L_{\text{GD}}=21 \mu\text{m}$, $L_{\text{G}}=43 \mu\text{m}$
 $L_{\text{D}}=10 \mu\text{m}$, $W_{\text{G}}=500 \mu\text{m}$